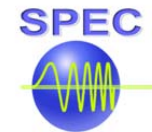


Solitronics, *LLC*



NC STATE UNIVERSITY



Development of High Voltage SiC Emitter Turn-Off Thyristor (ETO)

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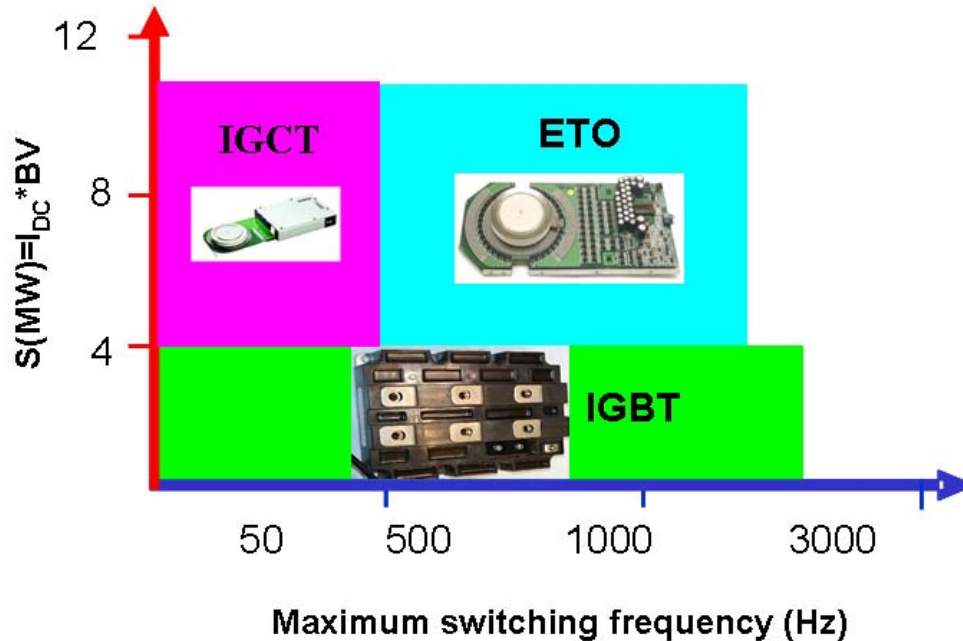
Problem statement:

Low cost, reliable, high efficiency power control and storage technologies are needed to handle increasing levels of power flow in distribution and sub-transmission applications including integration of renewable energy resources.

How to address this problem:

- **10 kV-12 kV SiC Emitter Turn-off (ETO) Thyristor**
- **5 kHz switching capability**
- **100 A current rating.**
- **Large current module using multichip module packaging (MCM)**
- **Superior to Si IGBT and MOSFET**
 - **Higher frequency operation**
 - **Lower conduction losses**
 - **Lower switching losses**

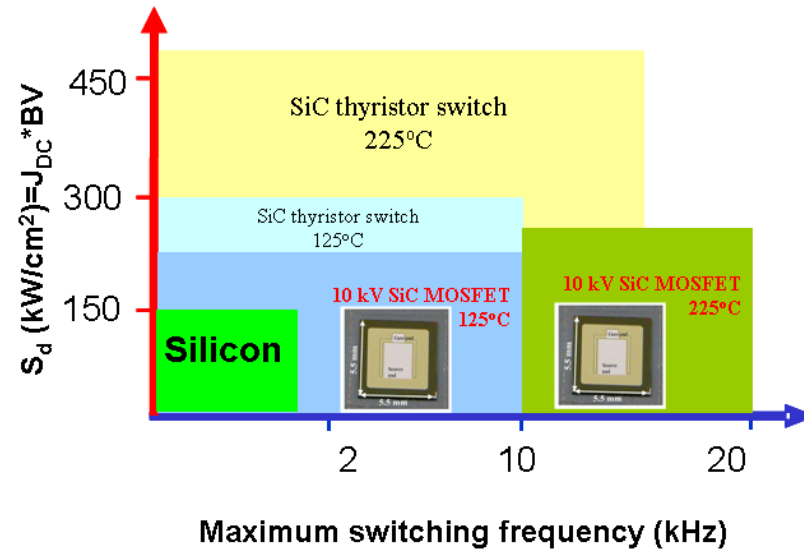
Limit of Si Power Devices



Si high power devices are approaching its physical limit:

- Voltage rating below 6.5 kV
- Operation frequency below 1 kHz
- Normal operation junction temperature is below 125 °C.

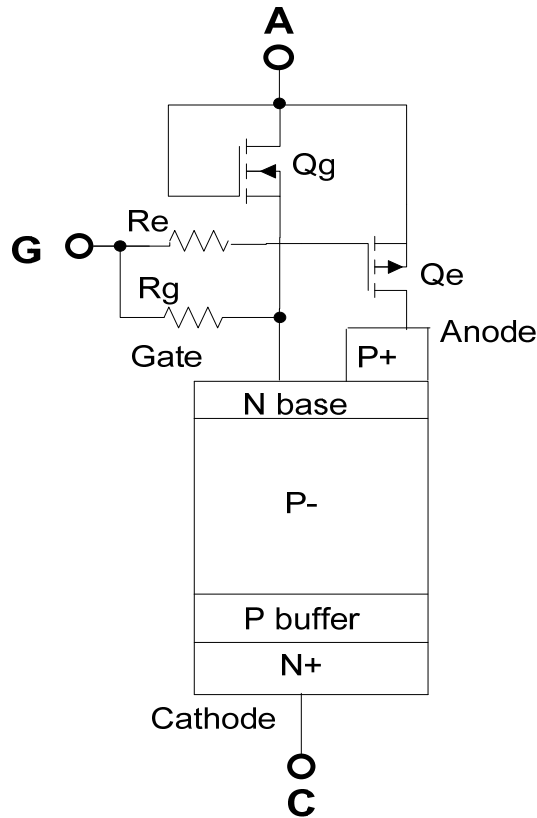
Motivation of SiC ETO



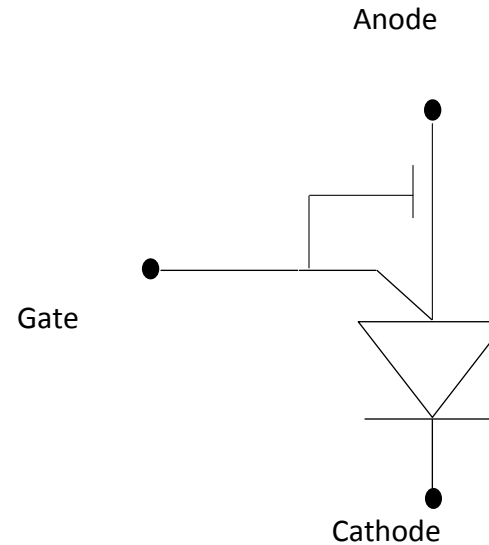
Advantages of SiC ETO:

- Improved switching speed
- High temperature operation capability
- Gate control.
- Better SOA

Schematic of p type SiC ETO

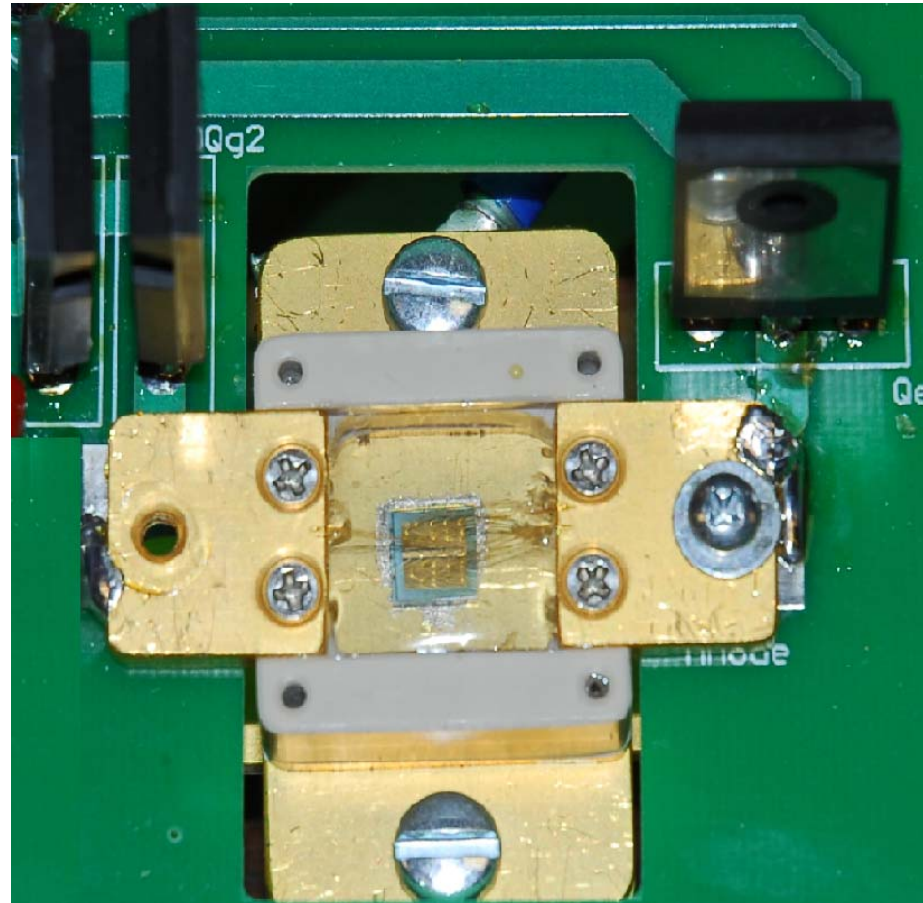


(a) p-type ETO equivalent circuit;



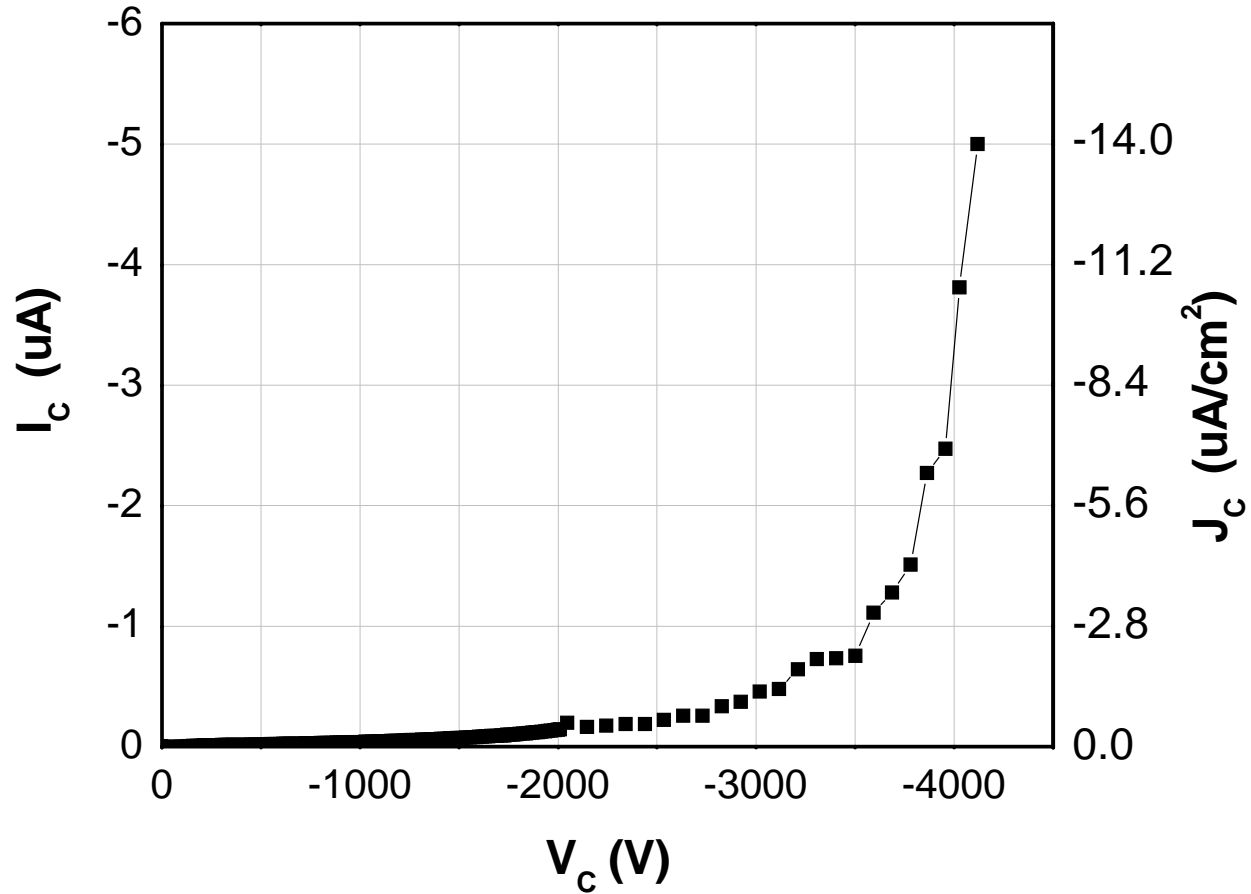
(b) corresponding ETO symbol.

World's first SiC ETO



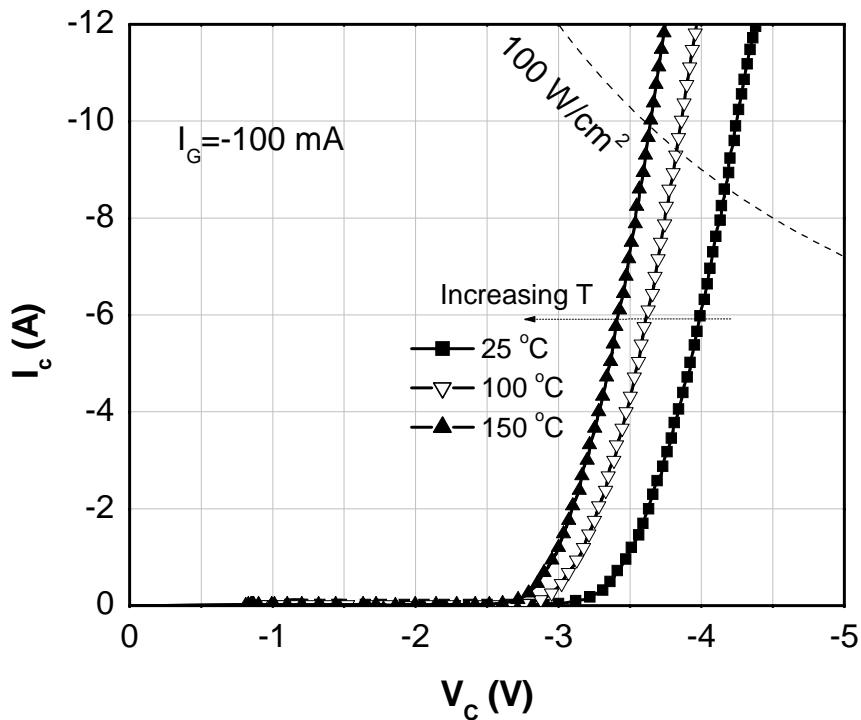
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Blocking Characteristics of SiC GTO

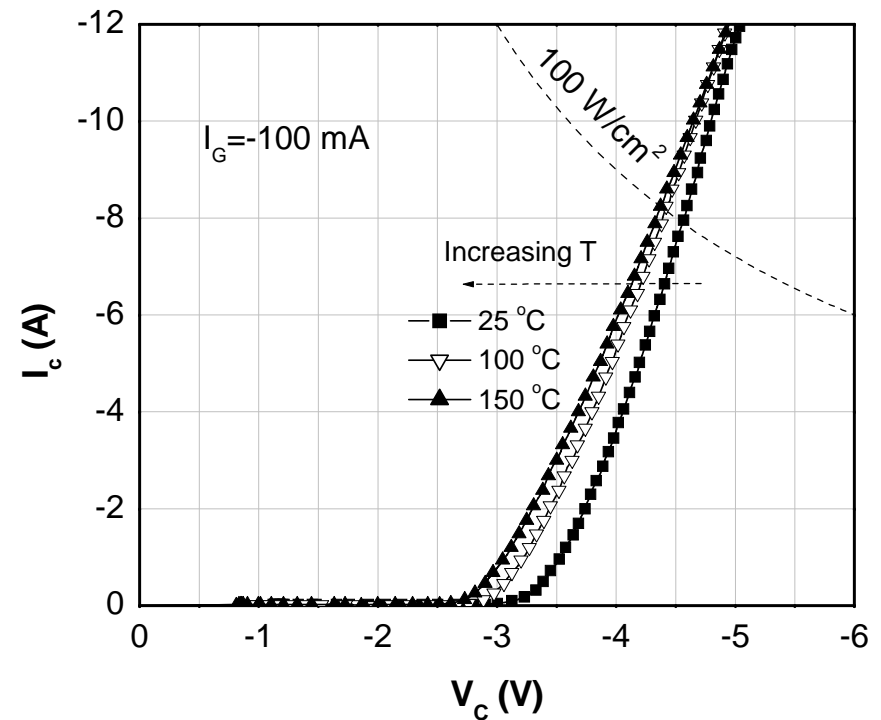


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DC Forward Characteristics of SiC GTO and ETO

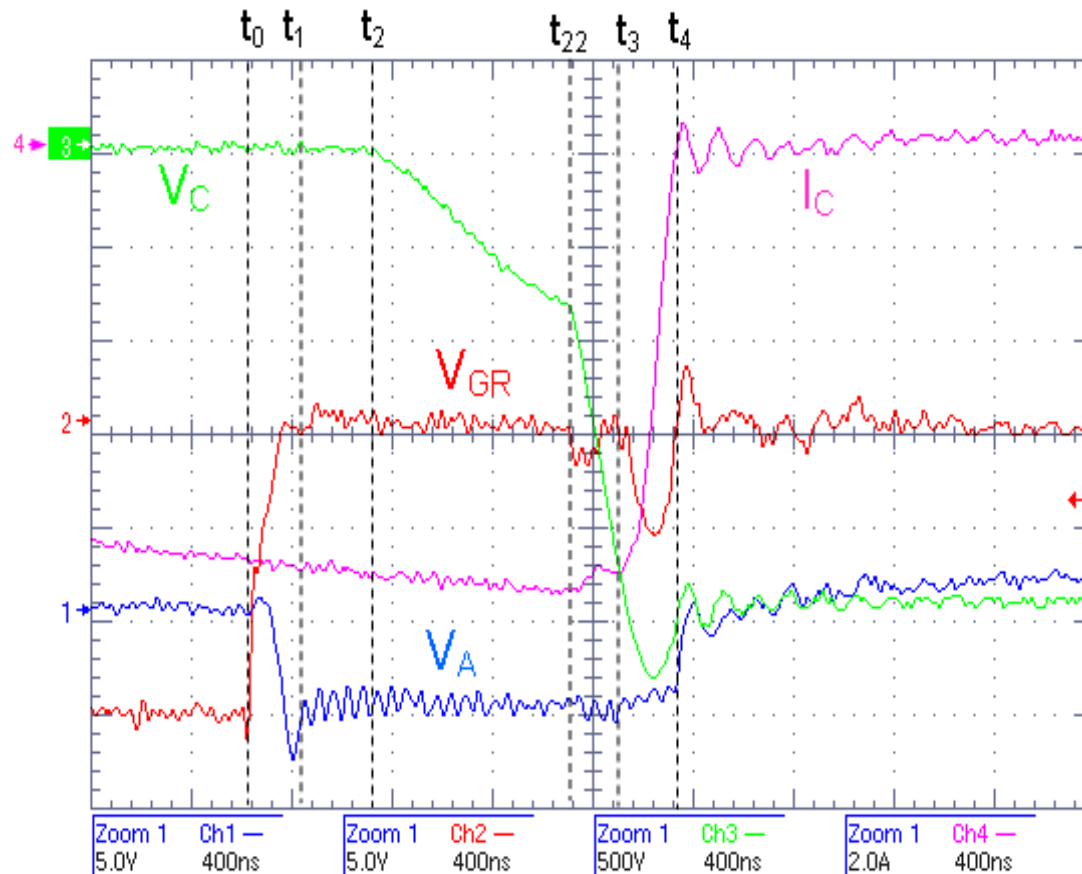


(a) SiC GTO



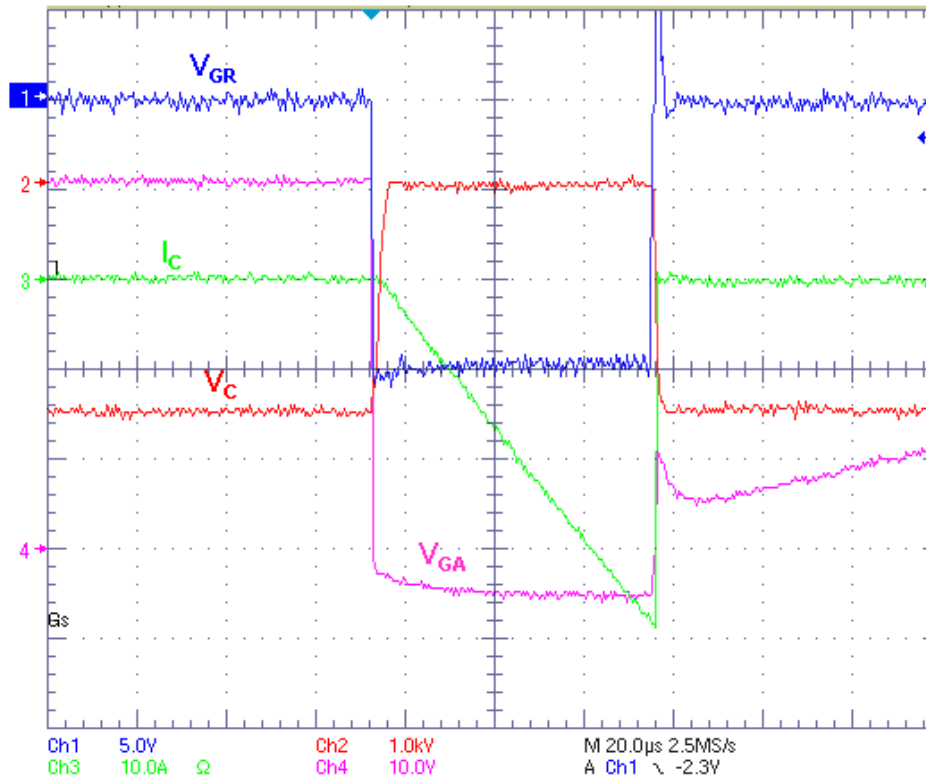
(b) SiC ETO

Transient Characteristics of SiC ETO



$E_{off} = 9.88\text{mJ}$ for 36 mm^2 SiC GTO, capable 8 kHz switching at $200\text{ }^\circ\text{C}$.

RBSOA study of SiC ETO

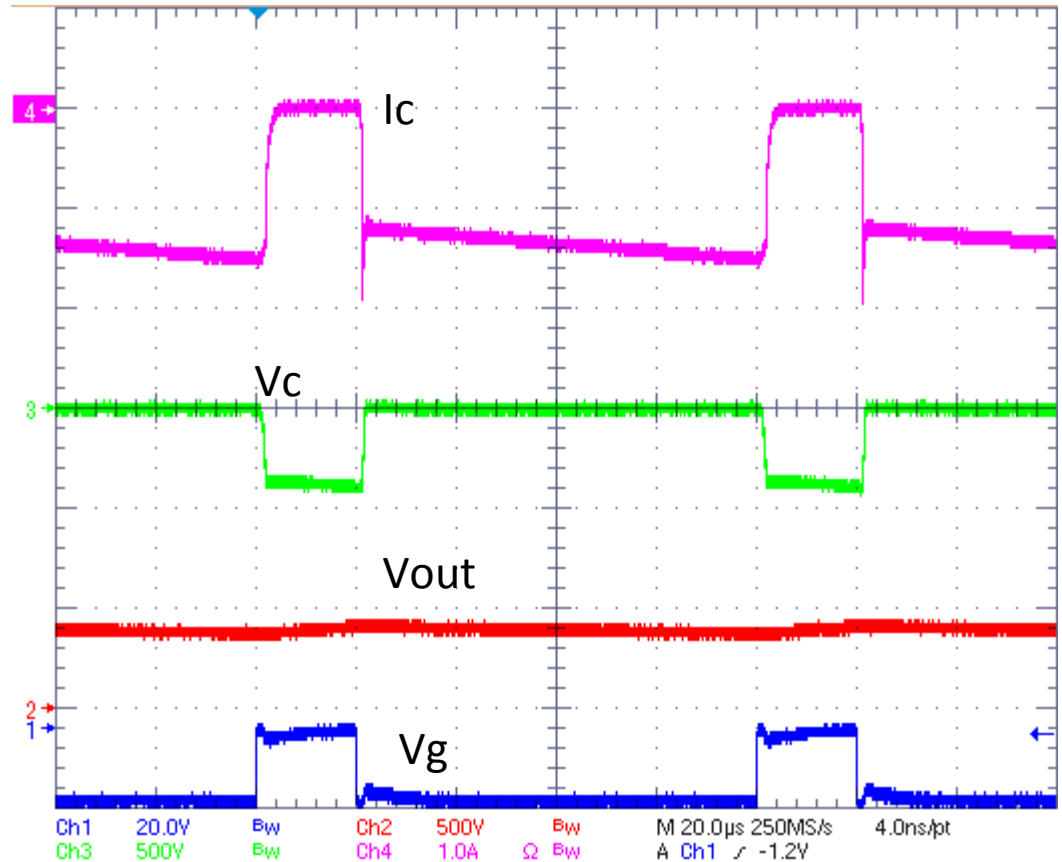
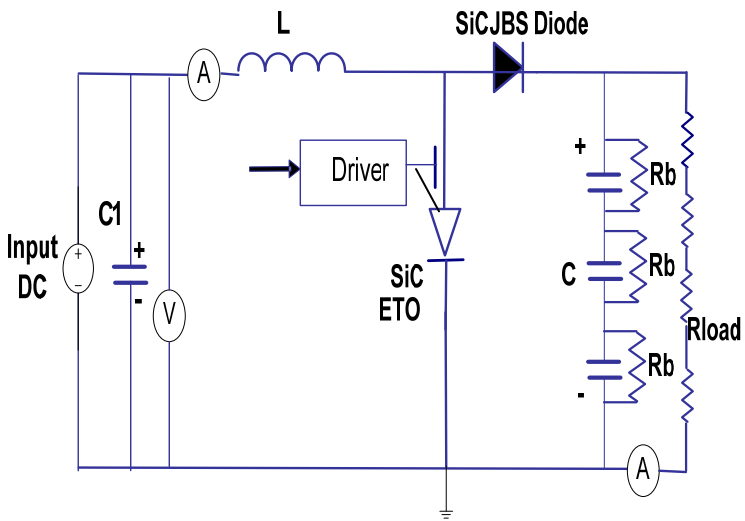


$$V_{DC-link} = 2.5 \text{ kV}$$

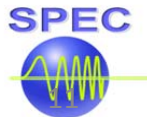
$$J_C = 100 \text{ A/cm}^2$$

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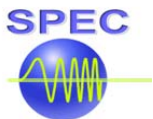
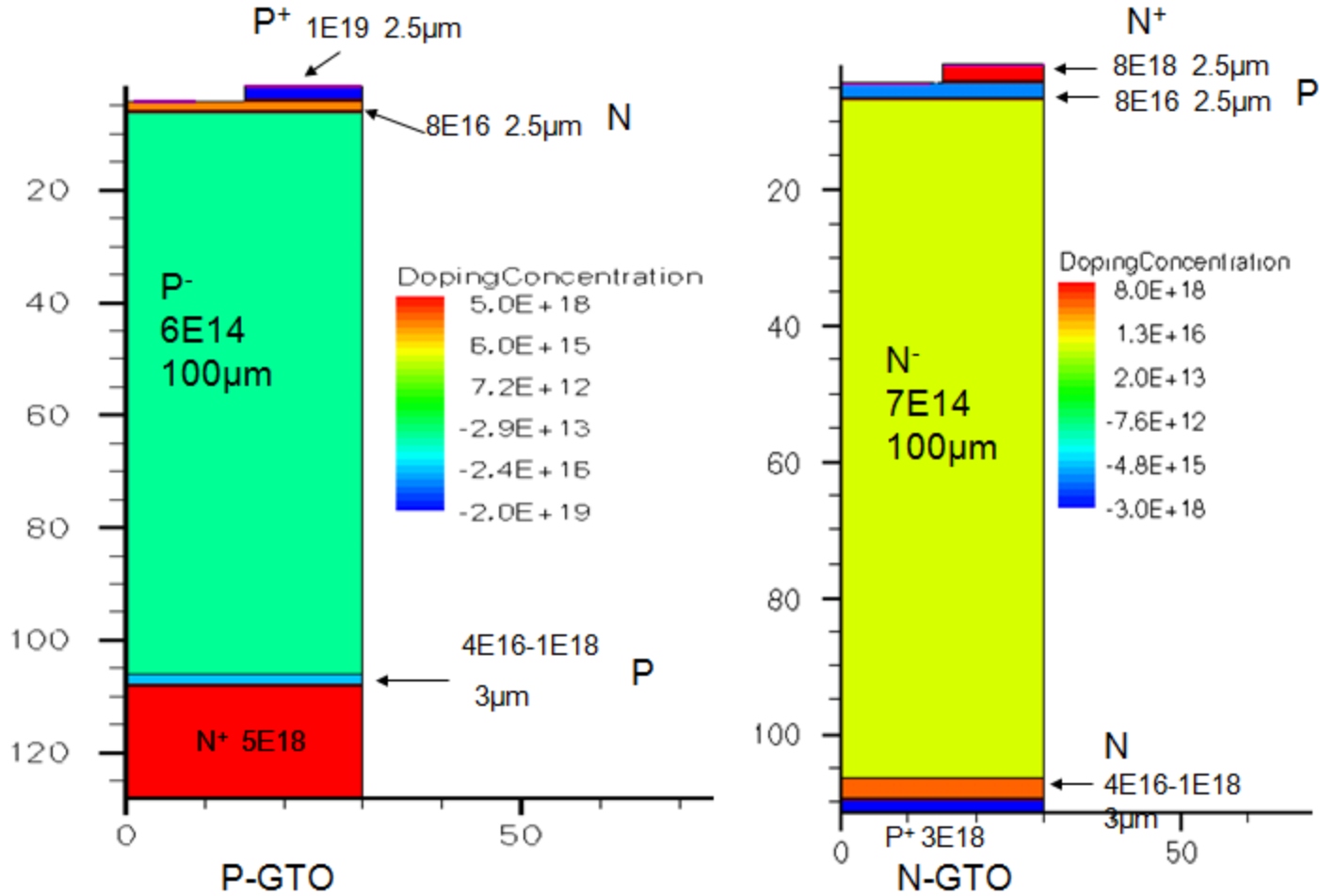
SiC ETO Based Boost Converter Demo



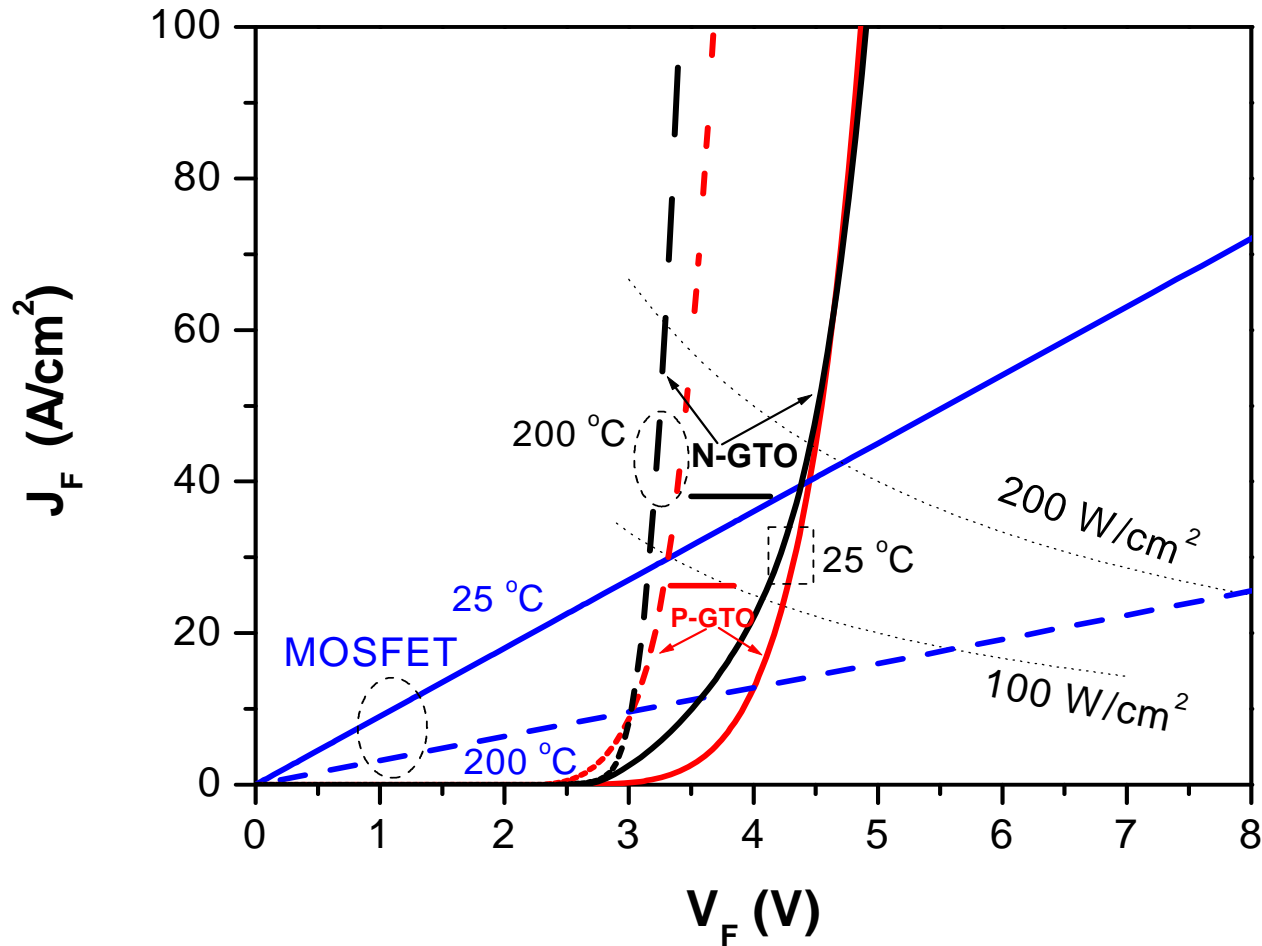
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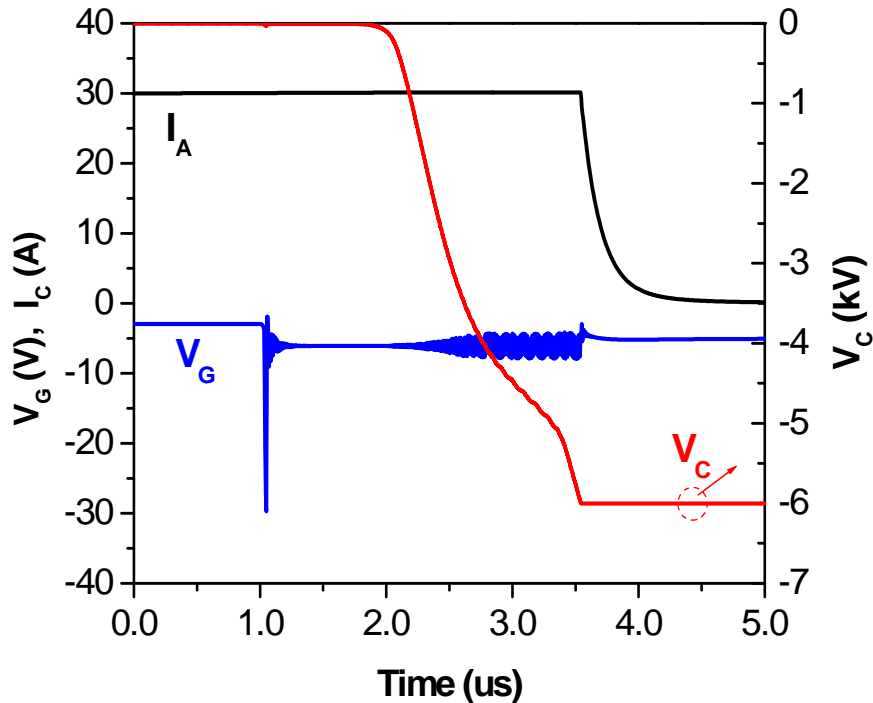
Design of High Voltage (10-kV) SiC GTO



Simulated DC Characteristics



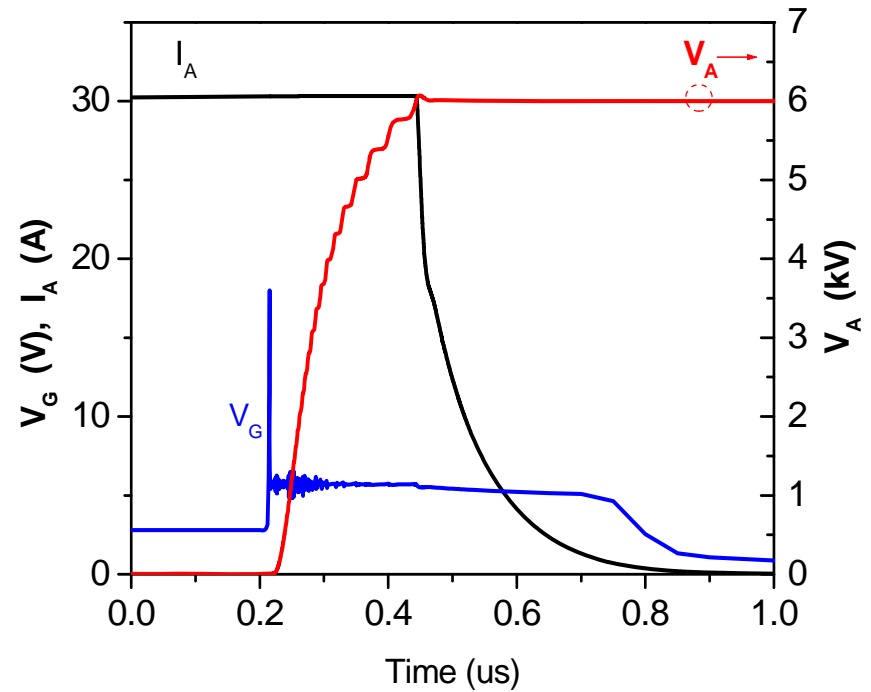
Simulated Transient Characteristics



p-ETO

$t_{\text{off}}=2.9 \mu\text{s}$

$E_{\text{off}}=190 \text{ mJ}$

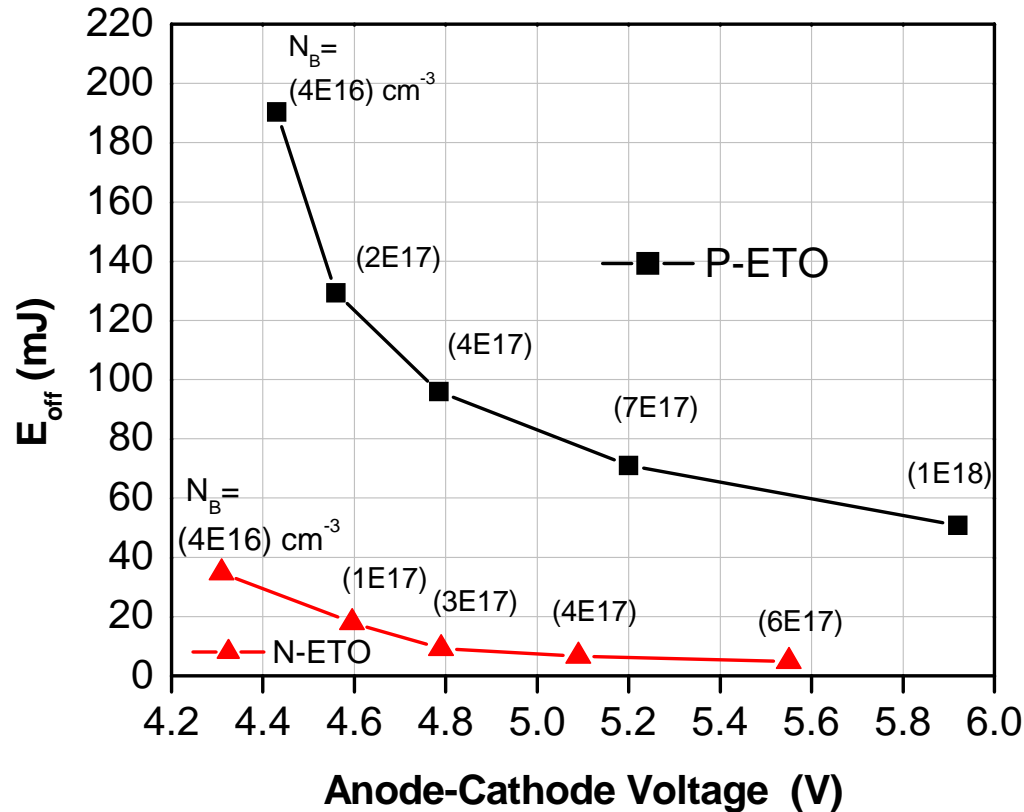


n-ETO

$t_{\text{off}}=0.52 \mu\text{s}$

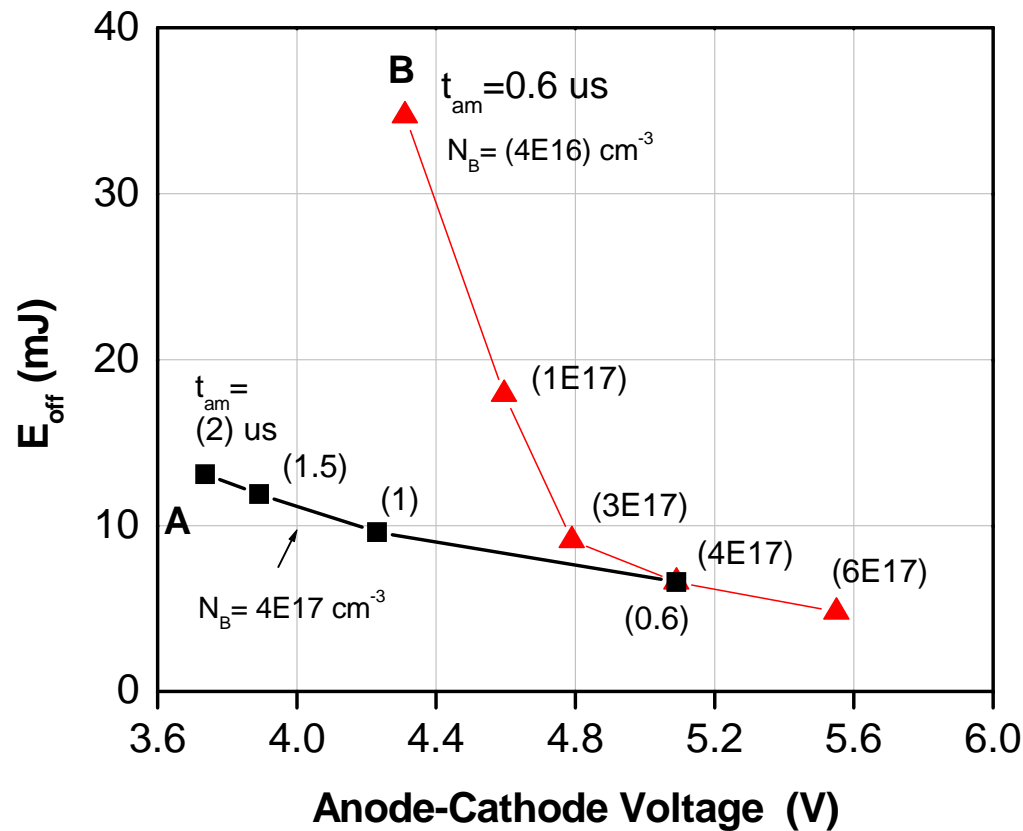
$E_{\text{off}}=34 \text{ mJ}$

Effect of Buffer Layer in SiC GTO



- 1) n-ETO can achieve about 8 times smaller turn-off energy, E_{off} , than p-ETO due to a small lower transistor current gain
- 2) E_{off} reduces by 81% (6.6 mJ) and V_F increases by 18% (5.05 V) when N_D increases from 4E16 cm³ to 4E17 cm³ for n type SiC ETO

Effect of Drift Layer Carrier Lifetime in SiC n-GTO



The n type SiC GTO with a long drift layer carrier lifetime is superior to those with a short drift layer carrier lifetime for the trade-off between on-state voltage and turn-off losses.

Summary

- We demonstrate the world's first 4.5 kV SiC ETO
- The fast switching speed and low loss of the 4.5 kV SiC ETO indicates the attractive potential of high voltage (>5 kV) SiC ETO especially for high voltage high frequency applications.
- Theoretical comparisons of 10 kV SiC n and p type SiC ETO shows the superiority of n type ETO, such as faster switching, due to very low switching losses and wide RBSOA.
- Further improvement of n type ETO can be made by the optimization of buffer layer and drift layer lifetime of SiC GTO

Further Work

- Development of 10 kV SiC n type ETO
 - 1) fabrication of 10 kV SiC n-GTO
 - 2) Characterization of 10 kV SiC n-ETO
 - 3) Application of 10 kV SiC n-ETO
- Study of Si/SiC heterostructure to reduce the turn-on knee voltage of SiC pn junction (~ 3 V)
 - 1) Theoretical analysis
 - 2) Experimental study

Questions ?

Thank you